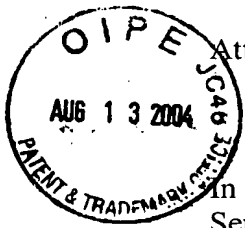


IFW



Attorney Docket No.: 5649-1129

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: Yun et al.

Group Art Unit: 2818

Serial No.: 10/629,280

Examiner: Thao P. Le

Filed: July 29, 2003

Confirmation No.: 5702

For: GATE STRUCTURES IN NONVOLATILE MEMORY DEVICE HAVING
CURVED SIDEWALLS FORMED USING OXYGEN PATHWAYS AND
METHODS OF FORMING SAME

August 11, 2004

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT AND AMENDMENT

Sir:

Applicant provides the present Response and Amendment to address the issues raised in the Restriction Requirement dated July 23, 2004. Applicant respectfully requests entry of this Amendment and allowance of the application.

It is not believed that an extension of time and/or additional fee(s), including fees for additional claims, are required, beyond those that may otherwise be provided for in documents accompanying this paper. In the event, however, that an extension of time is necessary to allow consideration of this paper, such an extension is hereby petitioned under 37 C.F.R. §1.136(a). Any additional fees believed to be due in connection with this paper may be charged to our Deposit Account No. 50-0220.

Amendments to the Claims are reflected in the listing of claims, which begin on page 2 of this paper.

Remarks/Arguments begin on page 5 of this paper.